## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of I hereby certify that this correspondence is being deposited HIROKI ADACHI with the United States Postal Service as first class mail in an envelope addressed to: the Commissioner for Patents, Washington, D.C. 20231 on Serial No.: Filed: November 16, 1999 Exposure Device, For: Exposure Method And Method of Manufacturing Semiconductor Device

Art Unit: 2814

Examiner: S. Rao

RECEIVED

MAY 1 4 2002

**Technology Center 2100** 

Commissioner for Patents Washington D.C. 20231

## **ELECTION AND AMENDMENT**

Sir:

In response to the Restriction Requirement October 1, 2001, Applicant elects prosecute Group III: Claims 8-33 in the above-identified application. Applicant is making this Election without prejudice to later filing a divisional application on the non-elected claims.

Please also amend the above-identified application as follows:

## IN THE CLAIMS:

Please add the following new claims:

09437649 00000013 501039 03/18/2003 CPARIS

02 FC:1202